

L Number	Hits	Search Text	DB	Time stamp
1	94863	(dielectric\$1 or oxide\$1) with (etch\$4 or plasma)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/04/03 13:03
8	23441	((dielectric\$1 or oxide\$1) with (etch\$4 or plasma)) same nitride	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/04/03 13:04
15	11	((((dielectric\$1 or oxide\$1) with (etch\$4 or plasma)) same nitride) and ((etch\$4 or plasma) with ("C.sub.4 F.sub.6")))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/04/03 13:06
22	4	((((dielectric\$1 or oxide\$1) with (etch\$4 or plasma)) same nitride) and ((etch\$4 or plasma) with ("C.sub.6 F.sub.6")))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/04/03 13:06
29	14	(((((dielectric\$1 or oxide\$1) with (etch\$4 or plasma)) same nitride) and ((etch\$4 or plasma) with ("C.sub.4 F.sub.6")))) or (((dielectric\$1 or oxide\$1) with (etch\$4 or plasma)) same nitride) and ((etch\$4 or plasma) with ("C.sub.6 F.sub.6")))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/04/03 13:06